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FABRICATION OF Cu(In,Ga)Se₂ THIN FILMS FOR HIGH EFFICIENCY SOLAR CELLS

Mr. Chanwit Chityuttakan

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	Solar Cells
By	Mr. Chanwit Chityuttakan
Field of Study	Physics
Thesis Advisor	Assistant Professor Kajornyod Yoodee, Ph.D.
Thesis Co-advisor	Assistant Professor Somphong Chatraphorn
	the Faculty of Science, Chulalongkorn University in Partial equirements of Degree of Doctor of Philosophy Dean of the Faculty of Science (Professor Piamsak Menasveta, Ph.D.)
	(Professor Piamsak Menasveta, Ph.D.)
Thesis Committee	
	(Associate Professor Prapaipan Chantikul, Ph.D.)
	(Assistant Professor Kajornyod Yoodee, Ph.D.)
	Semplang Chalsystoon Thesis Co-advisor (Assistant Professor Somphong Chatraphorn)
	Wichit Sritrakool Member (Associate Professor Wichit Sritrakool, Ph.D.)
	Withaya Amornhai Thamrung Member (Assistant Professor Vittaya Amornkitbamrung, Ph.D.)

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ได้ออกแบบและสร้างระบบเตรียมฟิล์มบางคอปเปอร์อินเดียมแกลเลียมไดซีลีไนด์ Cu(In,Ga)Se, (CIGS) สำหรับประดิษฐ์เซลล์แสงอาทิตย์ประสิทธิภาพสูงตามโครงสร้าง (Ni)AI/ZnO(AI)/CdS/CIGS/Mo/ SLG ซึ่งฟิล์มบาง CIGS มีความหนาประมาณ 2 ไมครอนถูกเตรียมบนแผ่นรองรับที่อุณหภูมิคงที่ รวมถึง การศึกษาผลกระทบของอุณหภูมิบนแผ่นรองรับที่ใช้ต่างกันคือ 475, 500, 525 และ 550°C ต่อฟิล์ม CIGS สำหรับวิธีการเตรียมฟิล์ม CIGS จะใช้วิธีการระเหยร่วมกันจากแหล่งระเหยธาตุทั้งสี่แหล่งร่วมกับเทคนิค การตรวจวัดสัญญาณ ณ เวลาจริง เพื่อใช้ควบคุมกระบวนการและซี้จุดสิ้นสุด (EPD) ในการทดลองเตรียม ฟิล์มบาง CIGS ได้ใช้โปร์ไฟล์อุณหภูมิ 2 แบบโดย แบบแรก Cu-Rich-Off (CURO) process เริ่มต้นปลูก ด้วย Cu-rich stage ให้ฟิล์มที่มีสัดส่วนอะตอมของ [Cu]/([In]+[Ga]) มากกว่าหนึ่ง (y > 1) แล้วต่อด้วย Cu-poor stage จนกระทั่งได้เนื้อฟิล์มทั้งหมดที่มีค่า y < 1 และหยุดปลูกที่ค่า $y \approx 0.9$ จากผลการ วิเคราะห์ฟิล์มด้วยวิธี XRD และ SEM แสดงว่าการปลูกแบบนี้ให้ฟิล์มที่มีโครงสร้างแบบชาลโคไพไรท์ โครง ผลึกส่วนมากหันระนาบ (112) ขนานกับระนาบของแผ่นรองรับ มีเกรนเป็นแท่งใหญ่ และผิวขรุขระมีรอย แตกแยกลึก เมื่อประดิษฐ์เป็นเซลล์แสงอาทิตย์แล้ววัดลักษณะส่อของกระแสและความต่างศักย์ไฟฟ้า (I-V) และประสิทธิภาพเชิงควอนตัม (QE) พบว่ามีประสิทธิภาพสูงถึง 14% ส่วนแบบที่สอง Cu-Poor-Rich-Off (CUPRO) process เริ่มต้นปลูกด้วย Cu-poor stage ด้วยค่า y < 1 แล้วต่อด้วย Cu-rich stage จน กระทั่งได้เนื้อฟิล์มทั้งหมดที่มีค่า v > 1 แล้วต่อด้วย Cu-poor stage จนกระทั่งได้เนื้อฟิล์มทั้งหมดที่มีค่า v < 1 โดยหยุดปลูกที่ค่าเดียวกัน ($y \approx 0.9$) จากผลการวิเคราะห์พบว่า ฟิล์มมีโครงสร้างแบบชาลโคไพไรท์ โครงผลึกหันระนาบ (220)(204) ขนานกับระนาบของแผ่นรองรับมากขึ้น มีเกรนเป็นแท่ง และมีรอยแตก แยกไม่ลึกจากขอบบนของเกรน เมื่อประดิษฐ์เป็นเซลล์แสงอาทิตย์แล้วได้ประสิทธิภาพสูงในระดับ 15% ในงานวิจัยได้เสนอแบบจำลองการเกิดของฟิล์มที่เตรียมจากทั้งสองวิธีซึ่งสอดคล้องกันคือ การมี Cu Se ส่วนเกินแยกตัวอยู่ที่ผิวฟิล์มและระหว่างขอบเกรนของฟิล์ม Cu-rich ซึ่งเป็นที่มาของรอยแตกแยกจากการ เปลี่ยนของ Cu_xSe ไปเป็น CIGS อีกทั้งมี recrystallization เกิดขึ้นในการเตรียมฟิล์มแบบ CUPRO process

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CHANWIT CHITYUTTAKAN: FABRICATION OF Cu(In,Ga)Se₂ THIN FILMS FOR HIGH EFFICIENCY SOLAR CELLS. DISSERTATION ADVISOR: ASST. PROF. KAJORNYOD YOODEE, PH.D. DISSERTATION COADVISOR: ASST. PROF. SOMPHONG CHATRAPHORN. 146 pp. ISBN 974-17-6039-6.

A deposition system for fabrication of high efficiency Cu(In,Ga)Se₂ (CIGS) thin films was designed and constructed. The structure of the CIGS solar cells consists of five different layers of materials, (Ni)Al/ZnO(Al)/CdS/CIGS/Mo/ SLG, where the SLG is the soda-lime-glass substrate. The CIGS absorber layers of approximately 2 µm thick were co-evaporated from four elemental sources onto the Mo/SLG substrates with constant substrate temperatures. The temperature effect on CIGS films was also studied using different substrate temperatures of 475, 500, 525 and 550°C. The *in situ* monitoring technique was employed for process control and end point detection (EPD). Two temperature profiles were performed in the CIGS deposition process. First, Cu-Rich-Off (CURO) process was started with the Cu-rich stage such that the atomic ratio [Cu]/([In]+[Ga]) was greater than 1 (y>1), then followed by the Cu-poor stage until y<1 was reached, and the process was finished at $y \approx 0.9$. Film analysis results using XRD and SEM showed that these films were typically (112) oriented chalcopyrite with large columnar grains and rough surfaces with deep crevices. From the current-voltage (I-V) and the quantum efficiency (QE) measurements, the CIGS thin film solar cells fabricated with this process yielded efficiencies up to 14%. In the second profile, Cu-Poor-Rich-Off (CUPRO) process started with the Cu-poor stage, y<1, followed by the Cu-rich stage until y>1, then finished with the Cu-poor stage at the same value ($y \approx 0.9$). The results showed that these films were weakly (220)(204) oriented chalcopyrite with columnar grains and smooth surfaces with shallow crevices. These CIGS thin films solar cells showed their efficiencies at the level of 15%. The proposed growth models for these two processes implicated that the excess Cu_xSe in the Cu-rich films segregated and presented at the surfaces of the films and between the grain boundaries. The crevices resulted from the conversion of the Cu_xSe to CIGS. Furthermore, recrystallization was found to occur in the CUPRO growth process.

Department	Physics	Student's signature. Chammit Chityuttakan. Advisor's signature. Kay om yod. Kocke. Co-advisor's signature Semplong Chatsaptorn
Field of study	Physics	Advisor's signature. Ray on you bocke.
Academic year	2004	Co-advisor's signature Sompling Chalsaptern

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